

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.	:	10/501,117	Confirmation No. 5689
Applicant	:	Takeo Okabe et al.	
371 Filed	:	January 14, 2005	
Art Unit	:	1742	
Examiner	:	Sikyin Ip	
Customer No.	:	00270	
Title	:	COPPER ALLOY SPUTTERING TARGET AND METHOD FOR MANUFACTURING THE TARGET	

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE TO RESTRICTION REQUIREMENT

Sir:

This is a timely response to the written Restriction Requirement dated September 21, 2007.

Election

In the present application, Applicants elect without traverse to prosecute the invention of **Group 2** directed to an Al-Cu alloy sputtering target. The claims of **Group 2** include claims 3, 4, 7, 8, 16-19 and 23-24. In claim 7, Applicants elect the element Al.

Please charge any deficiency or credit any overpayment for entering this Response to our
deposit account no. 08-3040.

Respectfully submitted,
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